



CRC – GROUP : CONNECTED ABROAD

40 YEARS

ENGINEERING CONTROLLED ENVIRONMENTS



GERMANY

CRC

BELGIUM



INDIA



120 EMPLOYEES

€ 20m

>1800 PROJECTS



EXPIERIENCE OF FOUNDER __





Pieter Doms
CEO and MD

MIETEC - ALCATEL

1983 - Lead facilities design FAB I

1984 – Construction manager FAB I

1985 – Facilities Manager

1988 – Manufacturing Manager

1991 – Project Manager FAB II

1994 – Director Operations

CRC

1998 – Founder CRC Belgium Branch

2005 – Co-General Manager CRC Germany

2013 - Founder CRC Engineering Belgium

2018 - Founder PTD Cleantech Solutions















EPCM-V Services







ENGINEERING

- Feasibility study
- Concept to Detail design
- Detailed 3D modelling
- Procurement support
- Construction management
- Project Management

VALIDATION

- Validation policies
- URS-GMP review analysis
- Risk Impact assessment
- FAT/SAT commissioning
- Qualification (DQ, IQ, OQ and PQ)



EPCM SCOPE



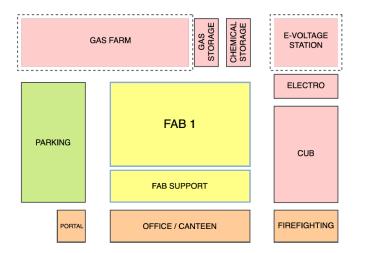
- Site Layout
- Building
- Lay-out
- Clean Room
- HVAC
- Clean Utilities
- Black Utilities
- BMS
- Safety and security

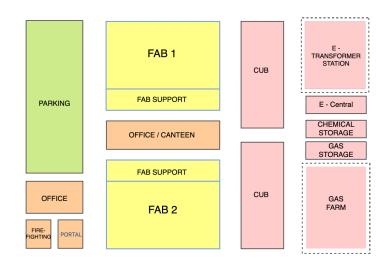






Master layout planning and conceptual planning is done keeping in mind the ergonomics and future expansion.





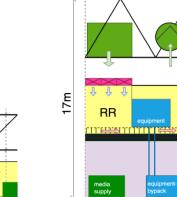


BUILDING CONCEPTS /

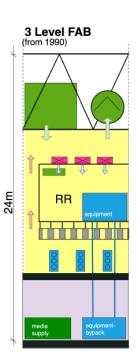


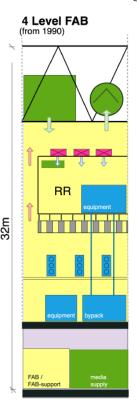
We have been designing semiconductor facilities over time with evolutions of building concepts

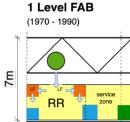
FAB building types



2 Level FAB (1980 - 2000)





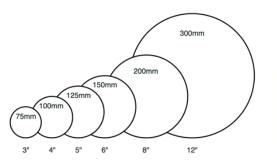






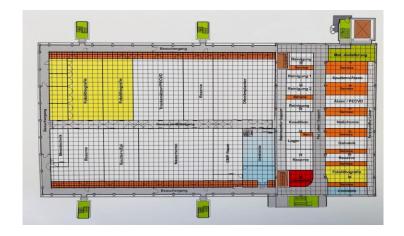
Internal layout planning is done keeping in mind

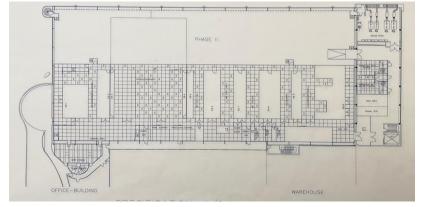
- The product
- The technology of production
- Overall space availability











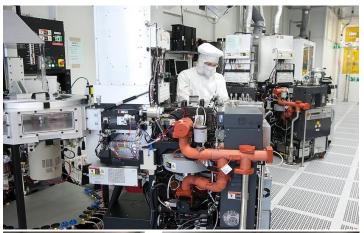


CLEAN ROOM



We have designed clean rooms for semiconductor manufacturing and research facilities in class ranges of Class 100 (stringent manufacturing and R&D) to Class 100000 (outside packing)



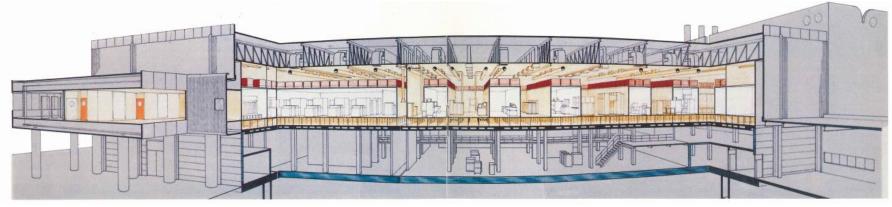








Ventilation being the primary and most important component of clean room design, we ensure that most optimum and operation friendly ventilation system is designed and realised.









CLEAN UTILITIES



Design of utilities (generation/distribution) coming in contact with the product















BLACK UTILITIES



Design of utilities auxiliary to the production process









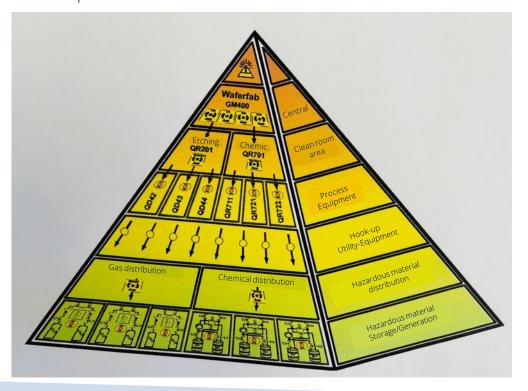


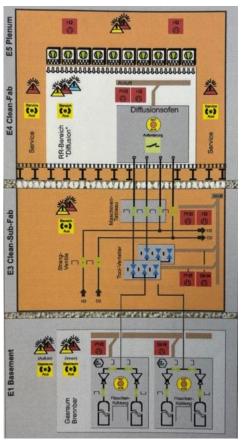






Safety system is designed considering minimum loss of time of production and selective isolation/evacuation.









unec



BOSCH



























New construction 8" Silicon Carbide (SiC) Wafer Fab, Saarland Germany

Client: Wolfspeed

Services: Engineering, Procurement Assistance and Construction Management in

Partnership with Drees & Sommer

User requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning

Figures: Clean room space – 16,500sqm. Date: 2022-2025

Description: 200mm wafer size, Silicon Carbide



New construction 12" Wafer Fab, Itzehoe Germany

Client: Vishay Siliconix Itzehoe GmbH

Services: Engineering, Procurement Assistance and Construction Management

User requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning + equipment hook-up

Figures: Clean room space – 4000sqm. Date: 2021-2025

Description: 300mm wafer size, MOSFET







New center for cutting-edge technology, Memmingen Germany

Client: Rohde & Schwarz GmbH & Co. KG

Services: Engineering, Procurement Assistance and Construction Management

User Requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning

Figures : Size 18000 sqm. Clean room space – 5000 sqm. Date : 2021-2025

Description: New clean room production building as manufacturing center for complex

appliance and measurement techniques, equipment, microelectronics and

drone defense systems in Memmingem



Extension 12" Wafer Fab R B 300, Dresden Germany

Client: Robert Bosch GmbH

Services: Engineering, Procurement Assistance and Construction Management

User requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning + equipment hook-up

Figures: Clean room space – 4000 sqm. Date: 2022-2024

Description: 300mm wafer size







New production facility for micro-optics and sensor, Dresden Germany

Client: Jenoptik AG

Services: Engineering, Procurement Assistance and Construction Management

User Requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning

Figures: Clean room space – 2000 sqm. Date: 2021-2025

Description: Lithography, optoelectronic



New production area 4, Ditzingen Germany

Client: Trumpf AG

Services: Engineering, Procurement Assistance and Construction Management

User requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning

Figures: Clean room space – 5000 sqm. Date: 2018-2022

Description: New production building including three clean rooms







New construction 12" Wafer Fab, Villach Austria

Client: Infineon Technologies Austria AG

Services: Engineering, Procurement Assistance and Construction Management

User Requirements, pre-design, concept design, permitting design, tender,

contract awarding + layout planning

Figures: Space – 84,000 sqm Clean room space – 16,000 sqm. Date : 2018-2022

Description: 300mm wafer size, CMOS



New construction and remodeling 6" and 8" Wafer Fabs, Reutlingen Germany

Client: Robert Bosch GmbH

Services: Engineering, Procurement Assistance and Construction Management

User requirements, pre-design, concept design, permitting design, detail design, tender, contract awarding, construction management + layout

planning + equipment hook-up

Figures: Clean room space – 32,000 sqm. Date: 1993-today (continuous projects)

Description: At the Bosch semiconductor front-end site in Reutlingen, CRC has been

planning since 1993. During this period, CRC has constructed approx 32,000sqm of new clean room space. In addition, there are ongoing renovations in the existing facilities to meet the current technological

requirements.







Fab 3 expansion, Leuven Belgium

Client: IMEC

Services: Engineering, Procurement Assistance and Construction Management in

partnership with ISG

BIM Management, 3D scanning, pre-design, detail design, construction

management support + commissioning support

Figures: Clean room space – 2000 sqm. Date: 2022-2023

Description: R&D center. Expansion of existing clean room and associated installation

serving the existing clean rooms.



Fab 1 GaN 6" fab remodelling, Oudenaarde Belgium

Client: On Semiconductor (Now BelGan)

Services: Engineering, Procurement Assistance and Construction Management

User Requirement, Pre-design, detail design, tender, contract awarding, construction management, commissioning support, validation + layout

planning + equipment hook-up

Figures: New Clean room space – 300 sqm. (old was remodeled) Date: 2012-2015

Description: 150mm wafer size, GaN. In order to stay up to date with technology, On

semiconductor wanted to revamp their existing facility built in 1983. CRC has been involved in this remodeling right from user requirement up to

validation.







Fab 1 remodeling, Leuven Belgium

Client: IMEC

Services: Engineering, Procurement Assistance and Construction Management

Feasibility study, pre-design, detail design, construction management,

commissioning support

Figures: Clean room space – 5200 sqm. Date : 2019-2022

Description: R&D center. IMEC wanted to Revamp their existing clean room facility from

the perspective of technology update and energy efficiency, with least effect

to ongoing operations and associated installations.



THANK YOU





a CRC Engineering company

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